



中国科学技术大学

University of Science and Technology of
China

Design and Simulation of MAPS- based Inner Tracker for STCF

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University of Science and Technology of China



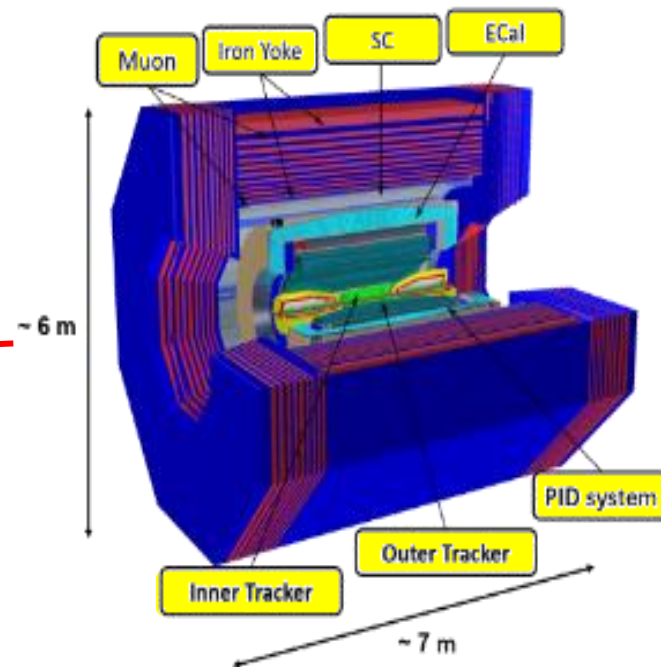
- Introduction to MAPS-based Inner Tracker (ITKM) for STCF
- MAPS sensor simulation and optimization
- ITKM simulation and performance
 - Introduction to OSCAR framework
 - Full simulation process
 - Detector simulation and digitization
 - Reconstruction performance
- Summary

Super Tau-Charm Facility



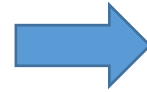
- **STCF: next generation e^+e^- collider in China**
 - Detailed study of $\tau - c$ physics
 - Precise tests to the SM
 - Searching for new physics
- $E_{cm} = 2\sim 7\text{GeV}$
- Peaking luminosity $> 0.5 \times 10^{35} \text{cm}^{-2}\text{s}^{-1}$

Unprecedented high luminosity brings challenges to all detectors, especially Inner Tracker



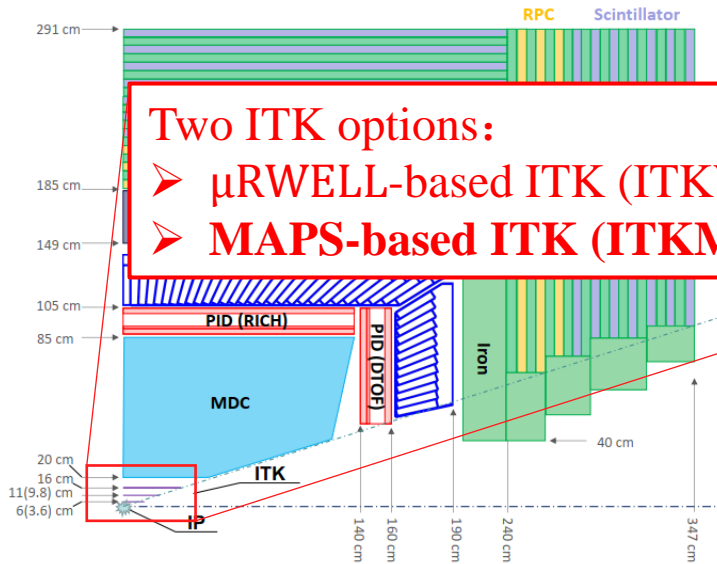
Requirements for Inner Tracker

- $0.3\% X_0$ per layer
- $\sigma_{r\phi} < 100\mu\text{m}$
- Tracking efficiency $>90\%$ @ $100\text{MeV}/c$
- Hit rate $\sim 800\text{kHz}/\text{cm}^2$



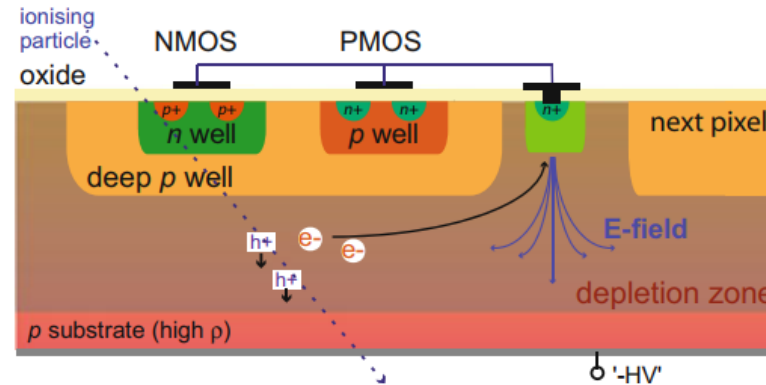
Requirements for MAPS

- Power consumption $< 100\text{mW}/\text{cm}^2$
- Moderate position resolution
- Good timing of $\sim 50\text{ns}$
- Detection of energy deposition



Two ITK options:

- μRWELL -based ITK (ITKW)
- MAPS-based ITK (ITKM)

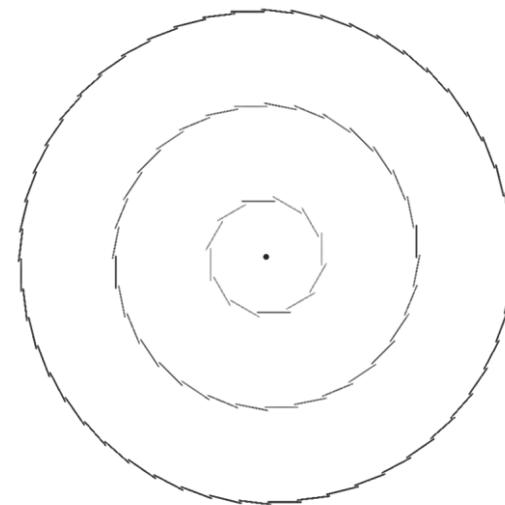
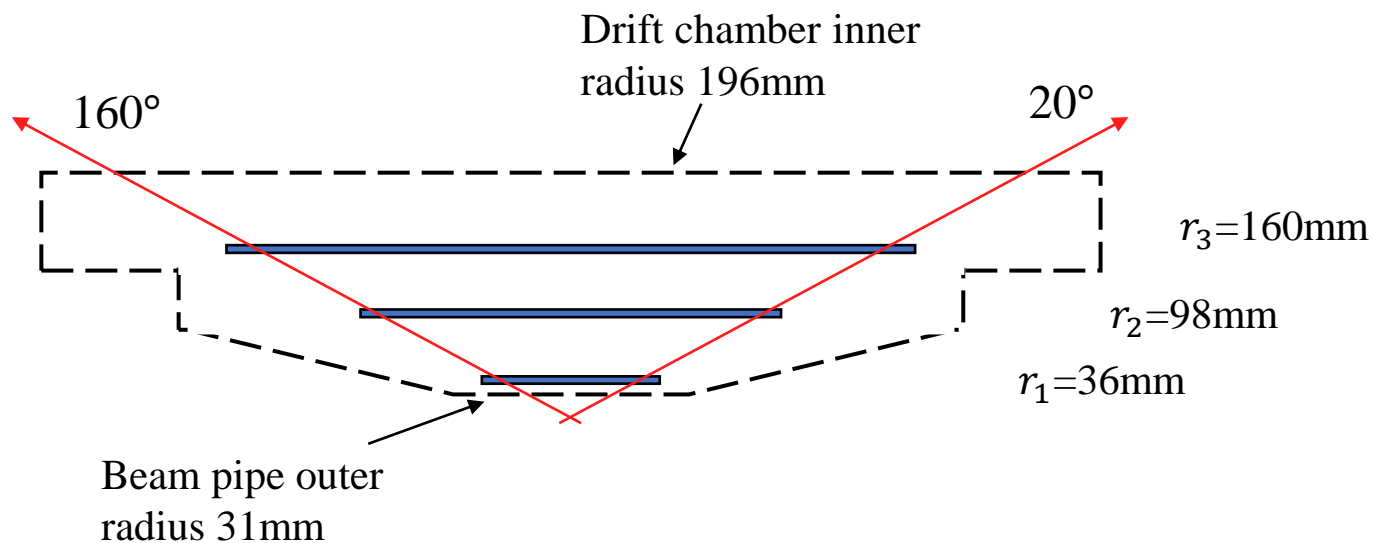


Monolithic Active Pixel Sensor

- ✓ Mature CMOS technology
- ✓ Highly integrated
- ✓ Small pixel pitch
- ✓ Low material budget
- ✓ High SNR
- ✓ ...

HR-MAPS with pixel size $170\mu\text{m} \times 30\mu\text{m}$ chosen as the baseline design for ITKM

Preliminary design of ITKM



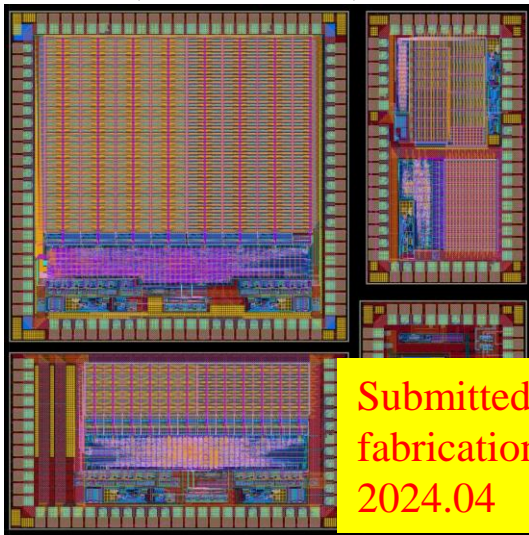
	Min radius	stave no.	sector no.	Area/cm ²
ITKM1	36mm	12	12	583.9
ITKM2	98mm	32	30	3892.7
ITKM3	160mm	52	48	10120.9

- Covering polar angle 20°-160°
- Total area: 15000 cm²
- Pixel numbers: 270 million

MAPS design going on under three different technologies

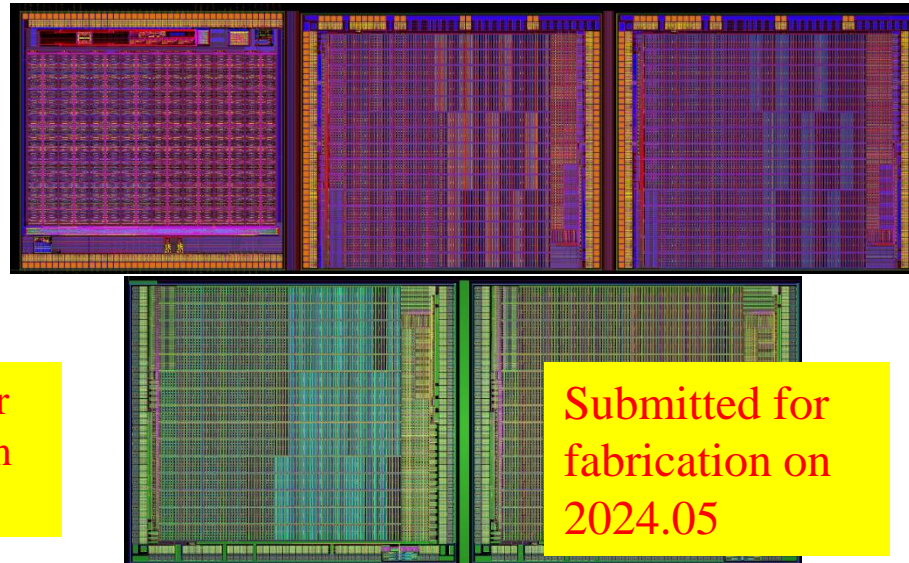
TJ180nm

- Widely used in HEP (ALPIDE, OBELIX)
- **Baseline techno**
- Low res substrate + high res ($>1k\Omega \cdot cm$) EPI



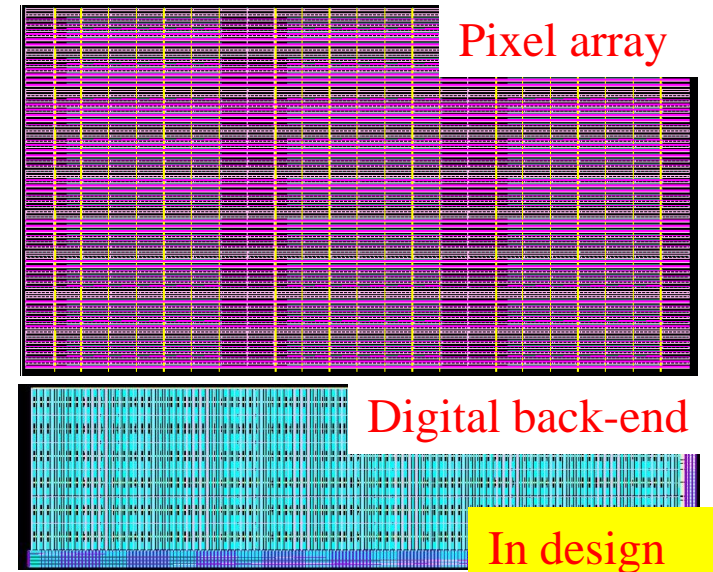
FCIS/BCIS90nm

- **Domestic techno**
- Low res substrate & EPI



GSMC130nm

- **Domestic techno**
- High res substrate, no EPI



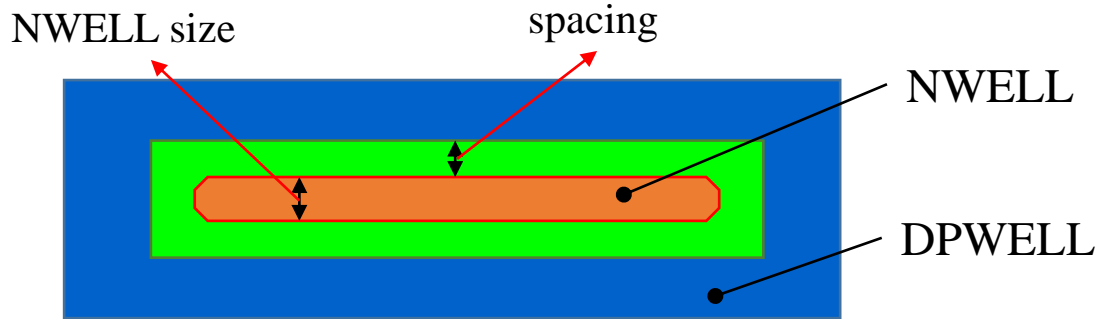
MAPS sensor simulation



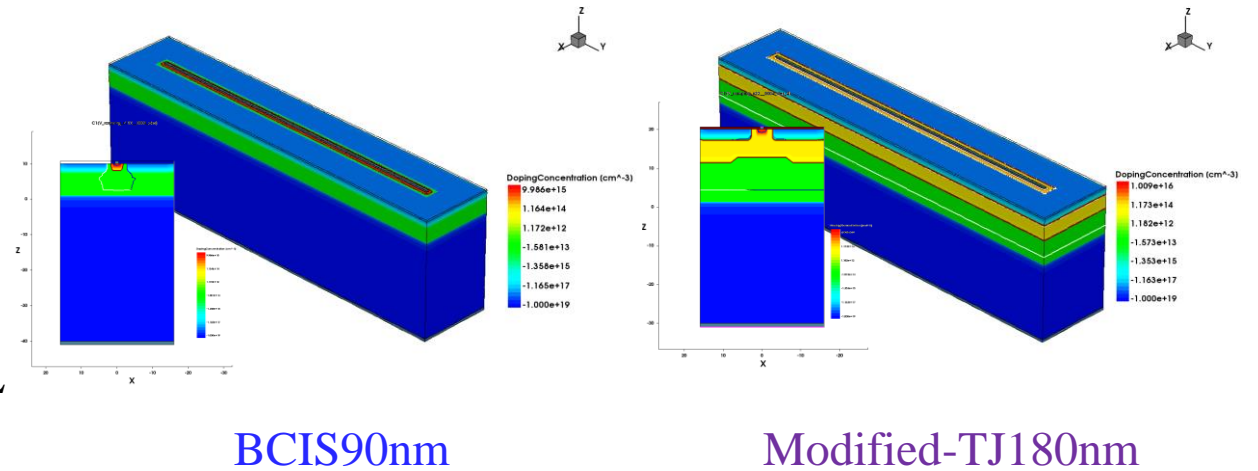
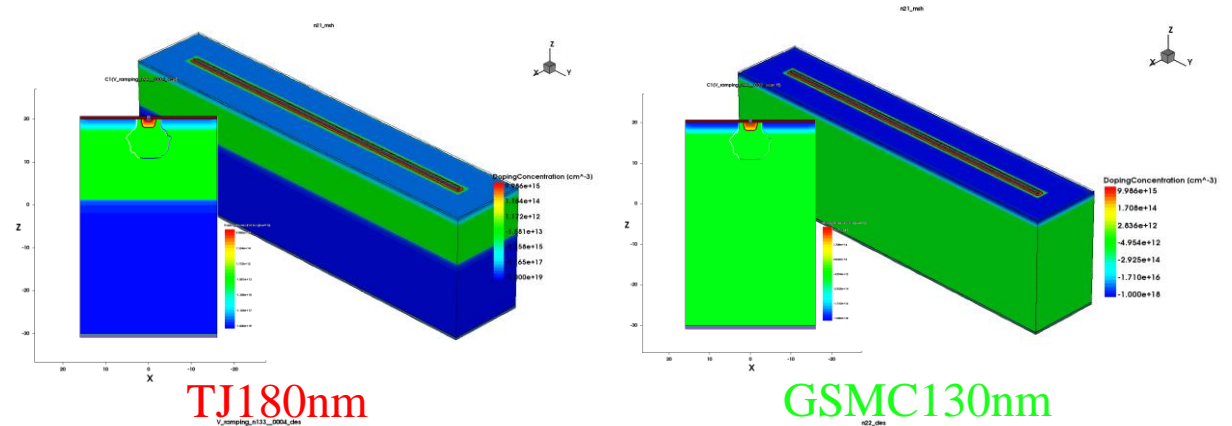
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- TCAD simulation in different technologies
- Pixel size: $170\mu\text{m} \times 30\mu\text{m}$
- NWELL size $2\mu\text{m}$
- NWELL-DPWELL spacing $2\mu\text{m}$
 - TJ180nm
 - GSMC130nm
 - BCIS90nm
 - Modified-TJ180nm (N-blanket design)



Doping profile

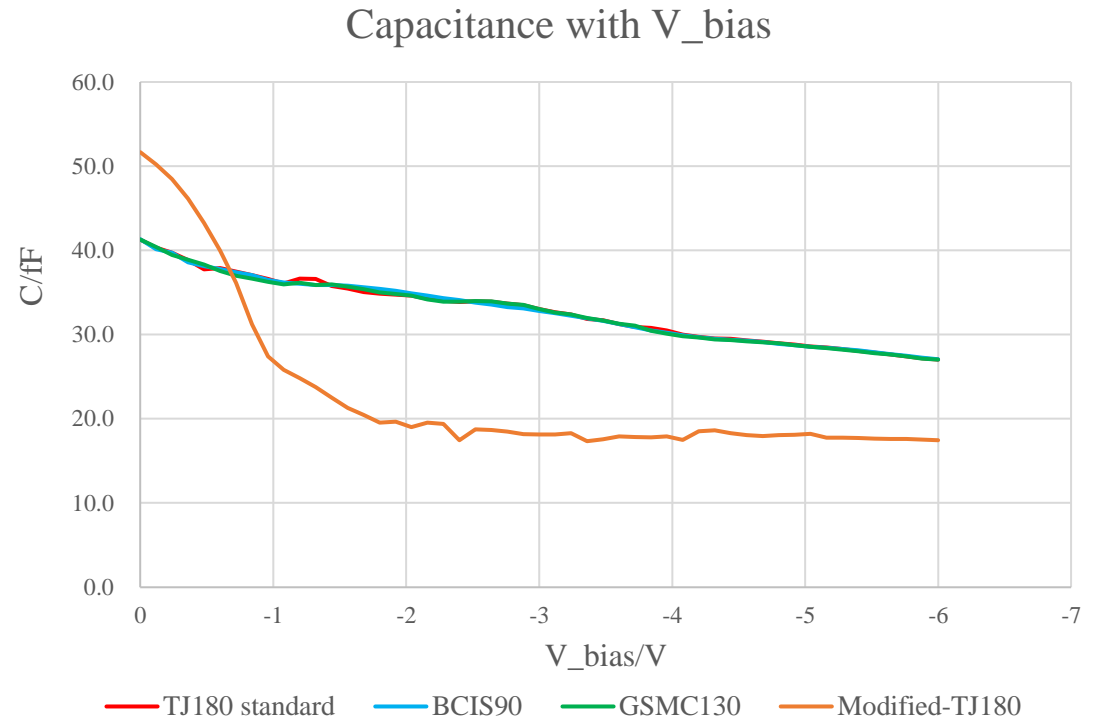


Sensor capacitance simulation



- Nwell voltage set to 0.8V, substrate voltage scanned from 0 to -6V

Techno	Capacitance @ $V_{sub} = -6V$
TJ180nm	27.0fF
GSMC130nm	27.1fF
BCIS90nm	27.0fF
Modified-TJ180nm	17.4fF

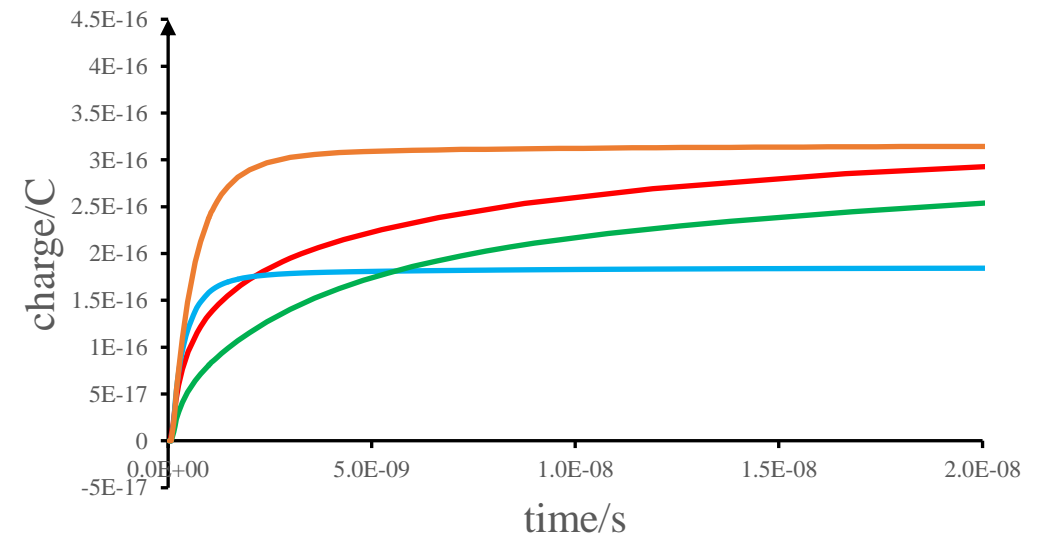
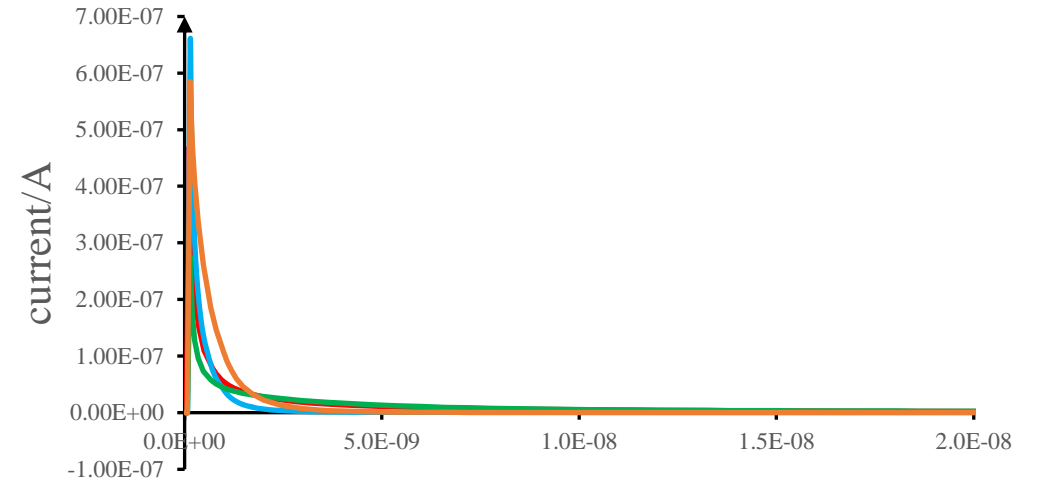


Sensor signal simulation



- **Ionization injection from center of pixel**
- Ionization density $80e^-/\mu m$
- Thresholds vary across different technologies

Techno	Collected charge (e)	Collection time(ns)	TOA @ threshold(ns)
TJ180nm	2039.81	20.56	0.21
GSMC130nm	2477.65	89.72	0.30
BCIS90nm	1153.17	1.28	0.16
Modified-TJ180nm	1969.85	1.81	0.20



— TJ180 standard — BCIS90 — GSMC130 — Modified-TJ180

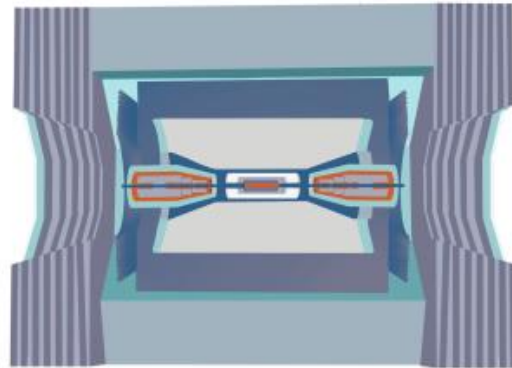
Introduction to OSCAR



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- The Offline Software of STCF (**OSCAR**) is designed for detector design, MC data production and physics analysis at STCF
- **External libraries & tools**
 - Podio, G4, ROOT, DD4hep ...
- **Core software**
 - common platform for the offline software
 - underlying framework: SNI_{PER}
- **Applications**
 - STCF specific application software



OSCAR

External Library/ Tools

Podio Geant4 ROOT
DD4hep Genfit CERNLIB

Core Software

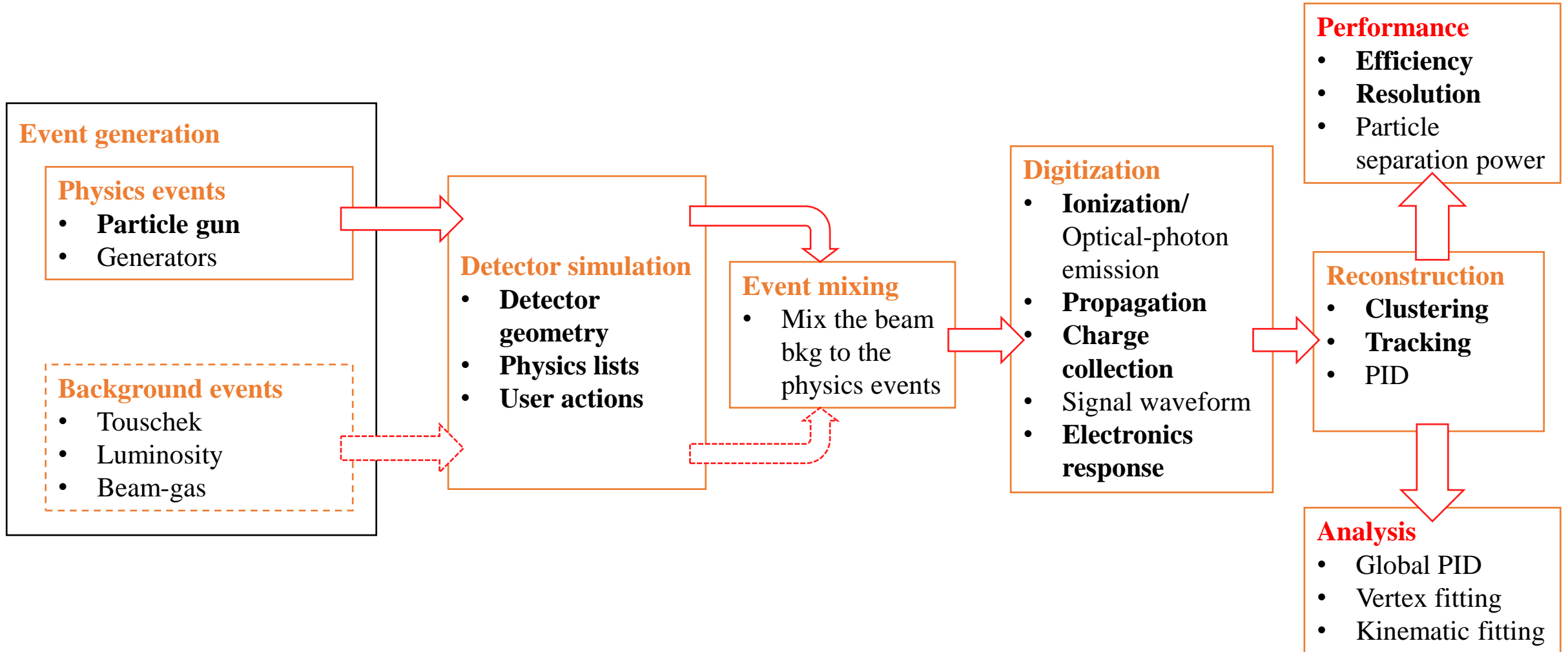
SNI_{PER} EDM
Database Data I/O

Applications

Generator Geometry Simulation
Digitization Reconstruction Analysis

OSCAR is now the common platform for full simulation of all sub-detectors

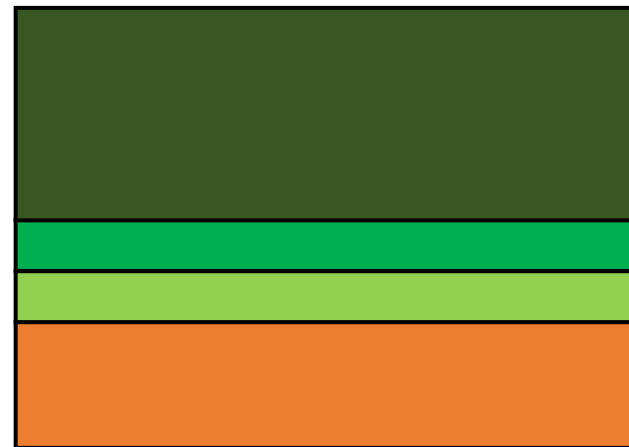
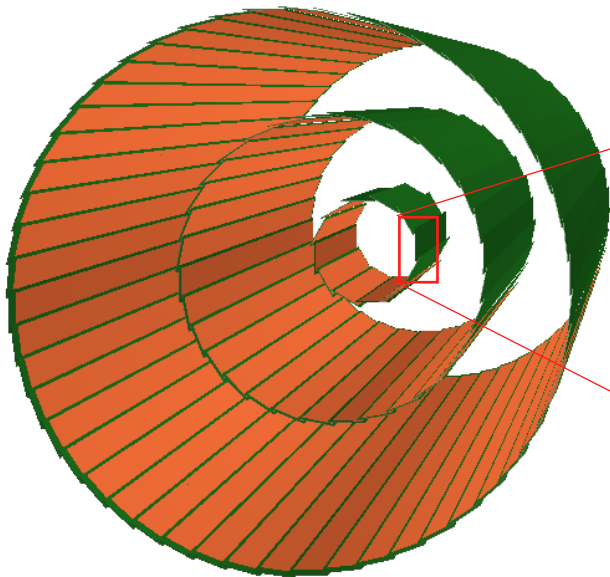
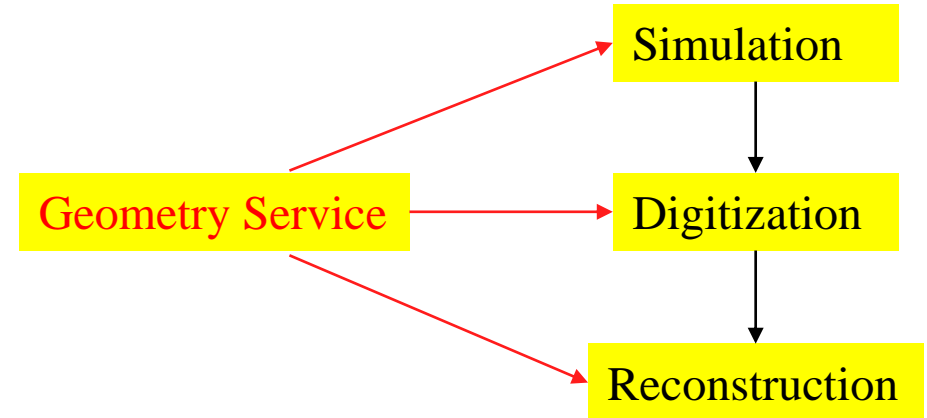
Full simulation process under OSCAR



ITKM geometry



- Geometry constructed by DD4hep
 - Stave width 2.2cm
 - Chip size 2cm × 2cm
 - Pixel geometry: 170μm × 30μm TJ180nm techno
 - Material budget **0.31% X_0** per layer



Kapton 500um

copper 10um

silicon 10um

silicon 50um

**Off-chip
electronics
& Support**

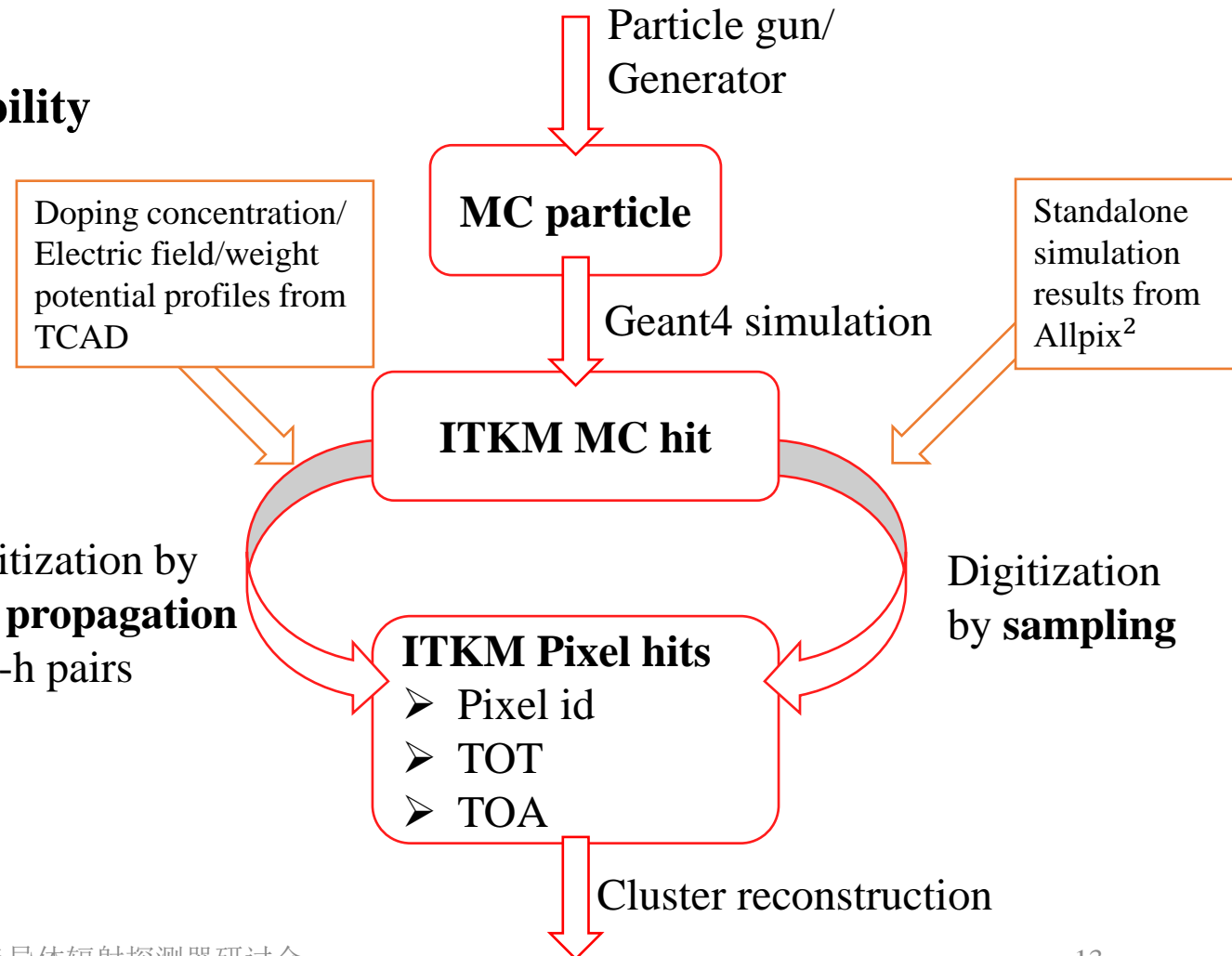
**On-chip
electronics**

Sensor

Simulation and digitization of ITKM



- **Digitization** is the bridge between simulation and reconstruction
- **Its accuracy largely determines the reliability of the full simulation**



Two different digitization methods implemented under OSCAR framework

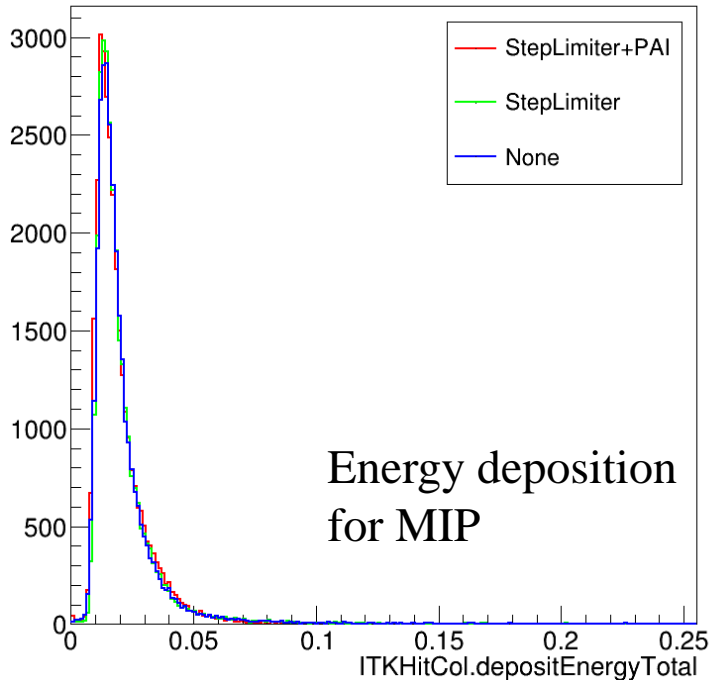
Simulation settings



In order to precisely simulate the ionization in $50\mu\text{m}$ silicon layer:

- Step limit in SV set to $10\mu\text{m}$
- Geant4 PAI model registered

All step information in SV is saved for the purpose of digitization



	Average steps per hit	Average secondaries per hit
StepLimiter+PAI	7.11	0.041
StepLimiter	7.14	0.0061
None	1.00	0.0056

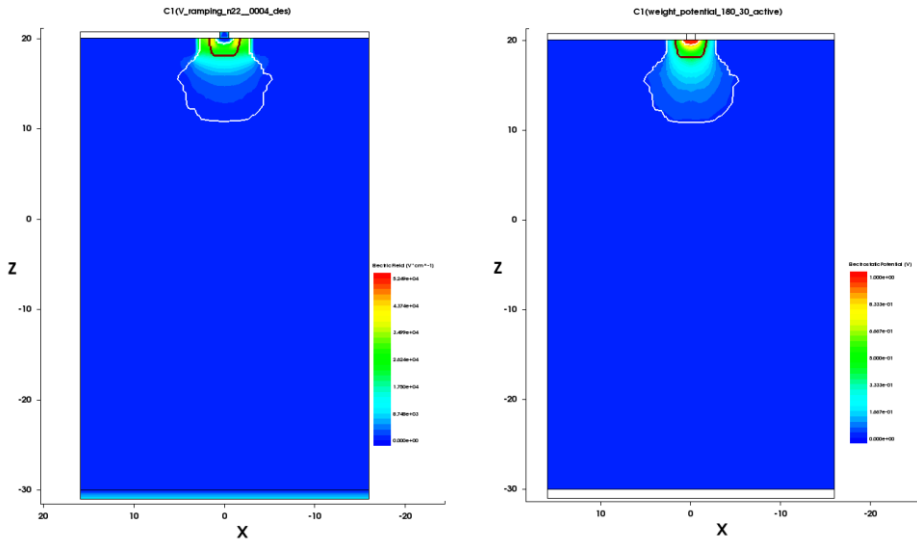
- Energy deposition does not vary much with model settings, MPV is about 15keV
- “StepLimiter+PAI” provides more steps as well as more accurate generation of secondaries

Digitization method 1



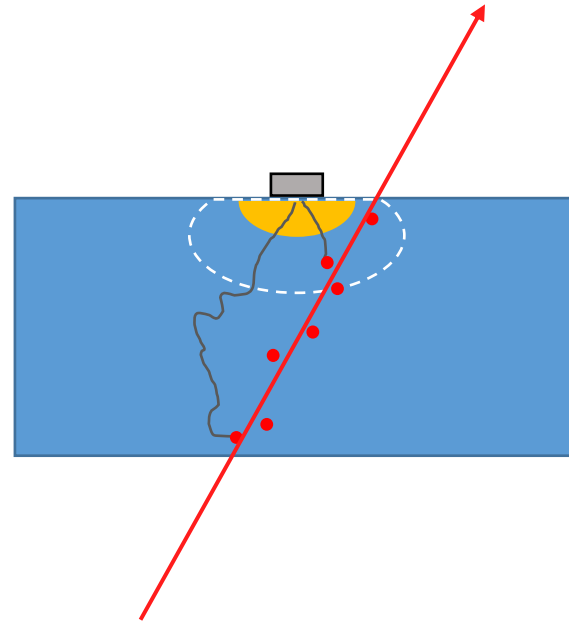
➤ “Full propagation” method

Precisely simulate the signal generation process in MAPS



electric field

weight potential



1. **Generating e-h pairs** according to deposit energy
2. **Simulation of e-h propagation**, including:
 - Drift
 - Diffusion
 - Recombination
 - Trapping & Detrapping
3. **Inducing charge** on electrode according to Ramo-Shockley theorem

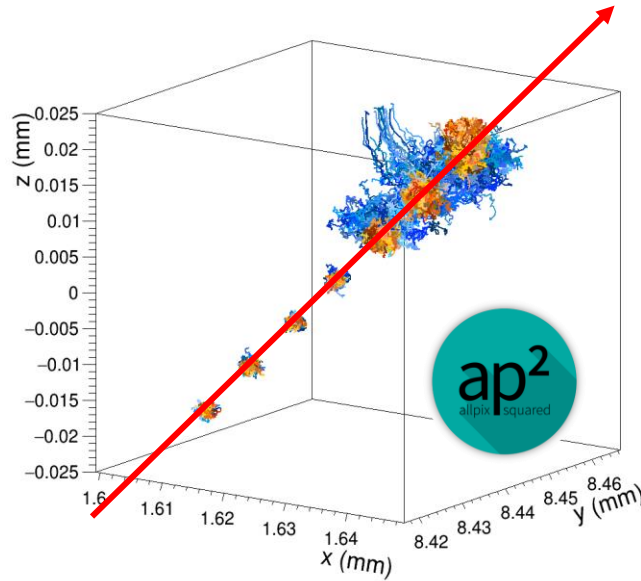
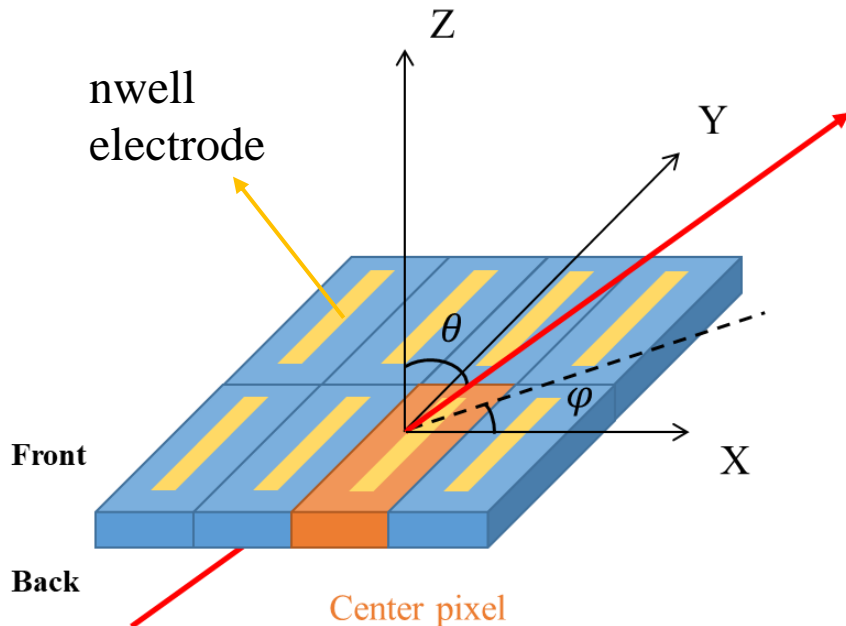
collected charge

Digitization method 2



➤ “Sampling” method

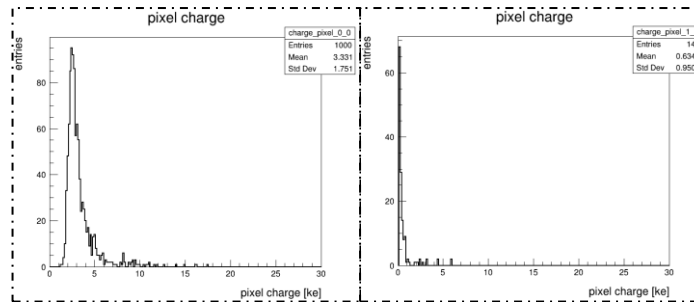
Pursue faster processing speed with the help of standalone simulation results



Incidence parameters are separated into a series of bins:

- θ (5 bins, 0-90°)
- φ (6 bins, 0-360°)
- **Energy deposit** (5 bins, 0-120keV)
- **Position** (5×5 bins)

Sampling from Allpix² result datasets

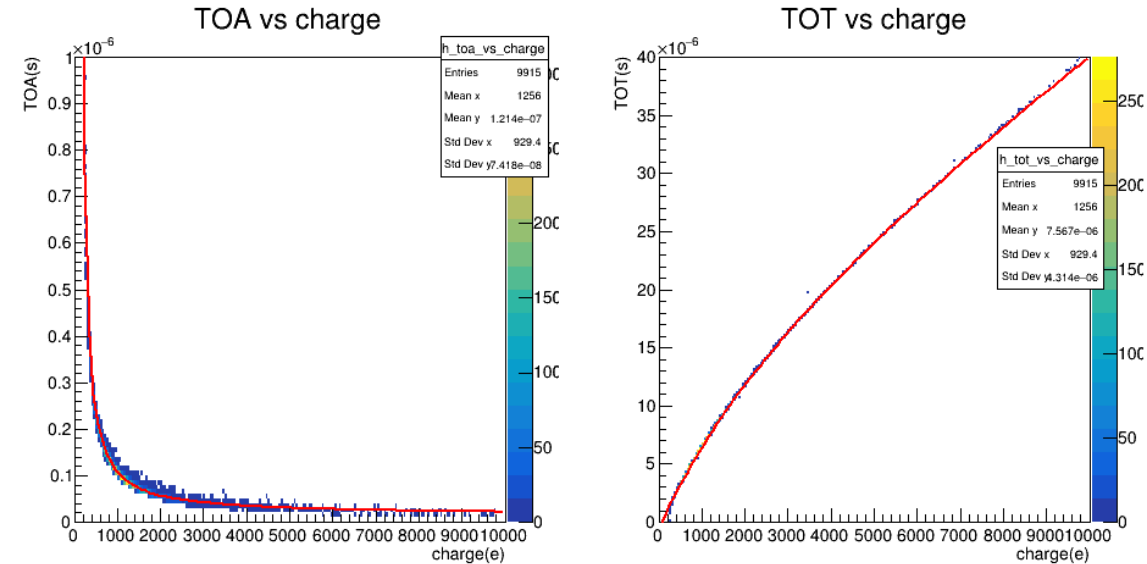
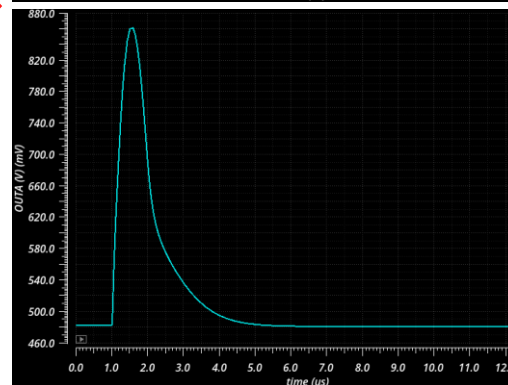
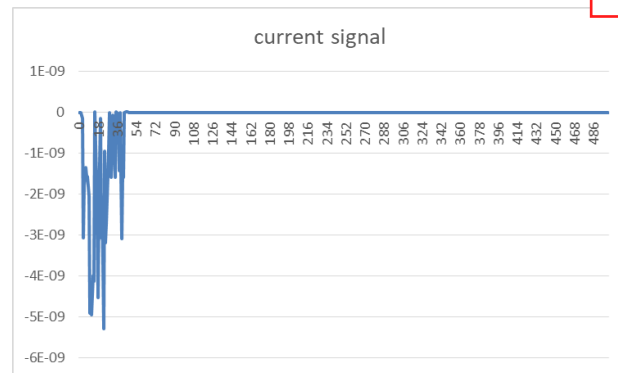
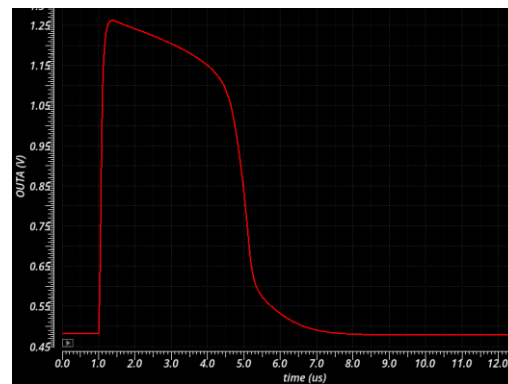
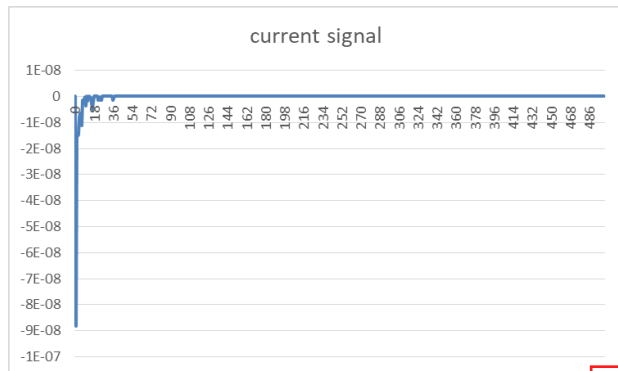


collected charge

Electronics response



- A series of sensor signals from randomly incident particles are fed to electronics simulation
- Voltage signals after analog front end are obtained
- TOA and TOT information is recorded

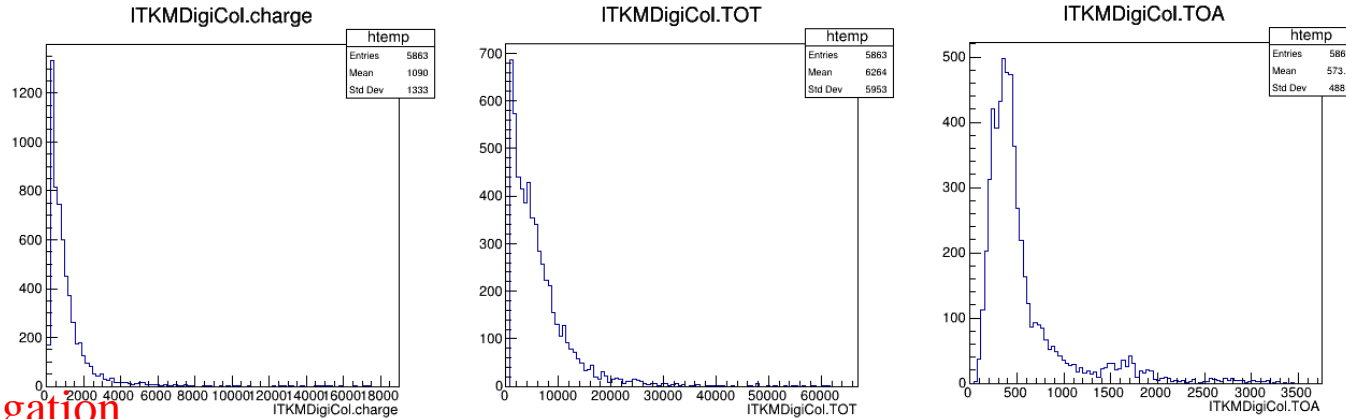


- Relationship between TOA/TOT and collected charge obtained
- Given a charge value, the TOA/TOT is calculated with a Gaussian smearing

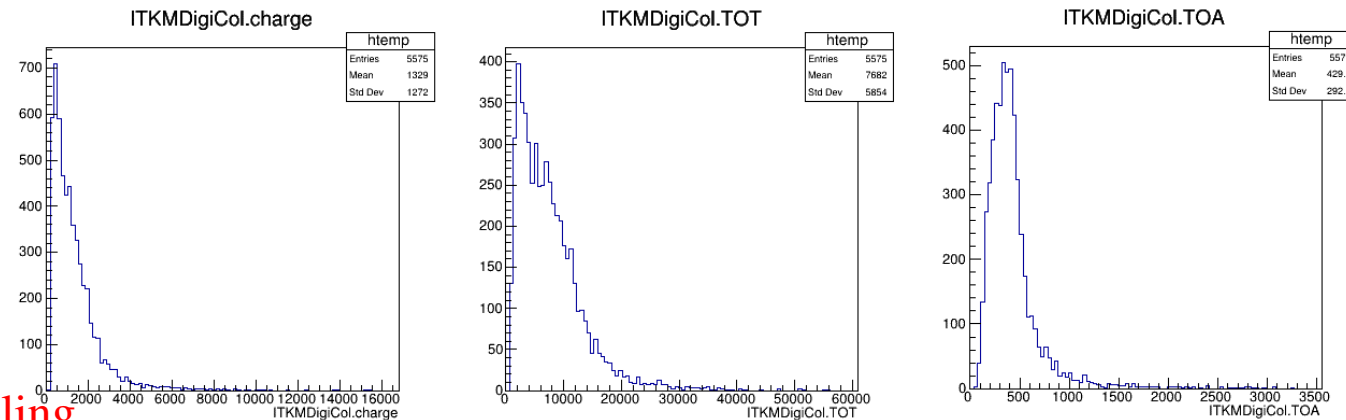
Digitization performance



Full propagation



Sampling



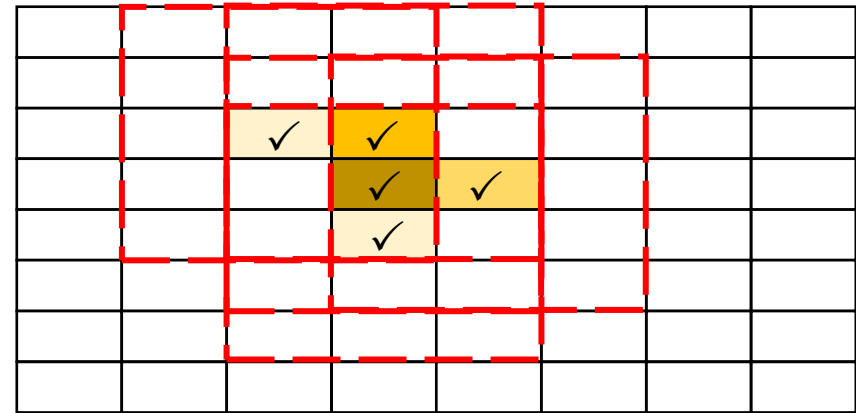
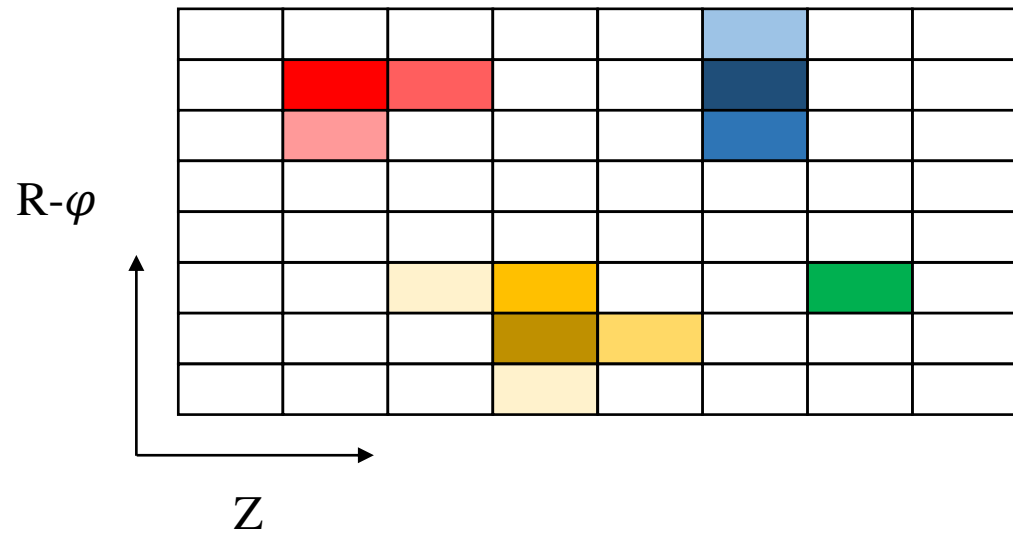
Method	Full propagation	Sampling
Memory usage	1.1G	Negligible
Time cost	48ms/hit	0.5ms/hit
Average collected charge per pixel	1080e ⁻	1329e ⁻
Average cluster size after reconstruction	1.835	1.755
	More accurate for small signals	Faster, less memory usage

Optimization for both methods is in progress

Cluster reconstruction



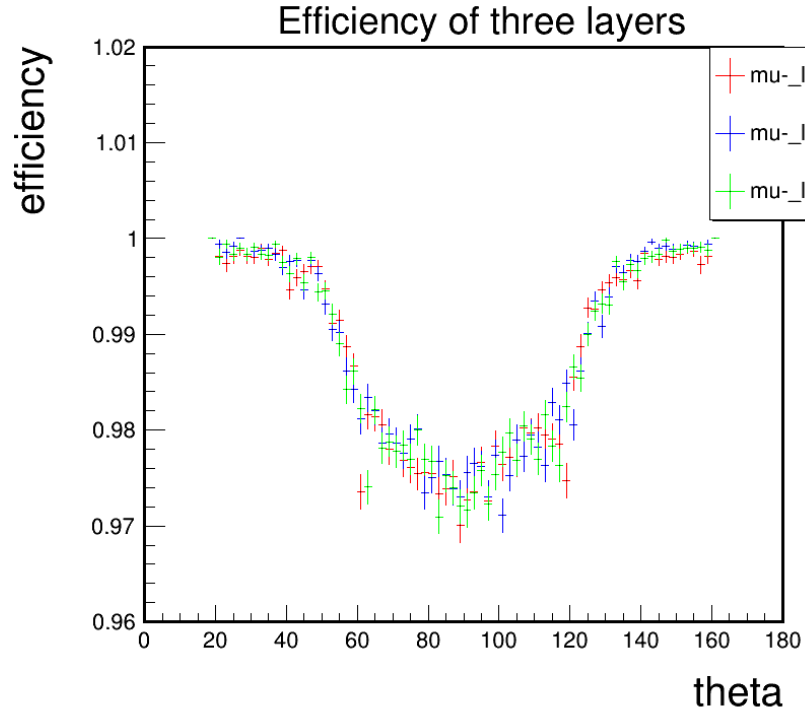
- **Cluster finding:** hit pixels inside $3*5(z*rphi)$ range classified as one cluster
- **Cluster position reconstruction:** charge centering (TOT converted to charge)



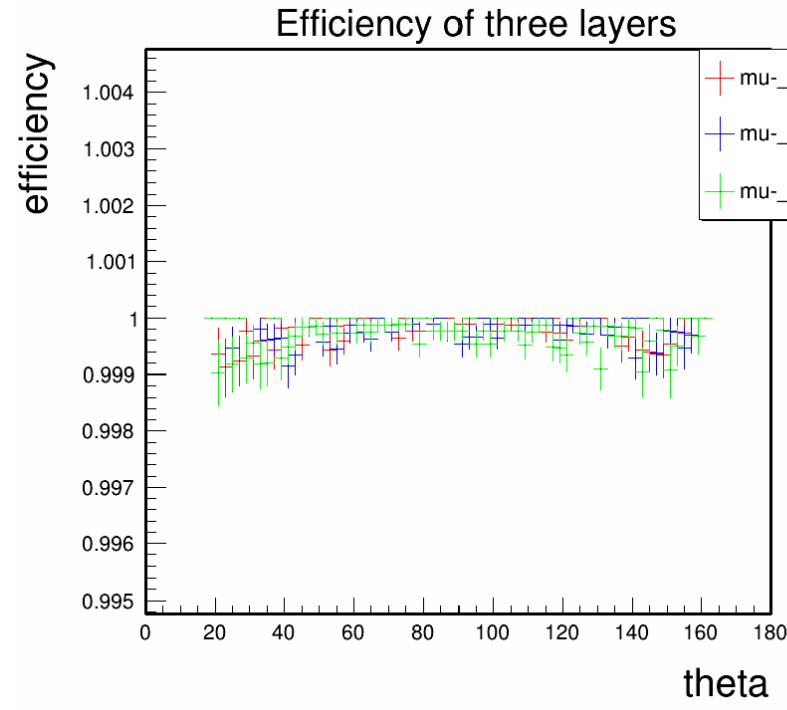
Efficiency



- Simulation settings:
 - 1GeV/c muon, θ range 20°-160°
 - Pixel threshold: 300e



Detection efficiency vs. polar angle



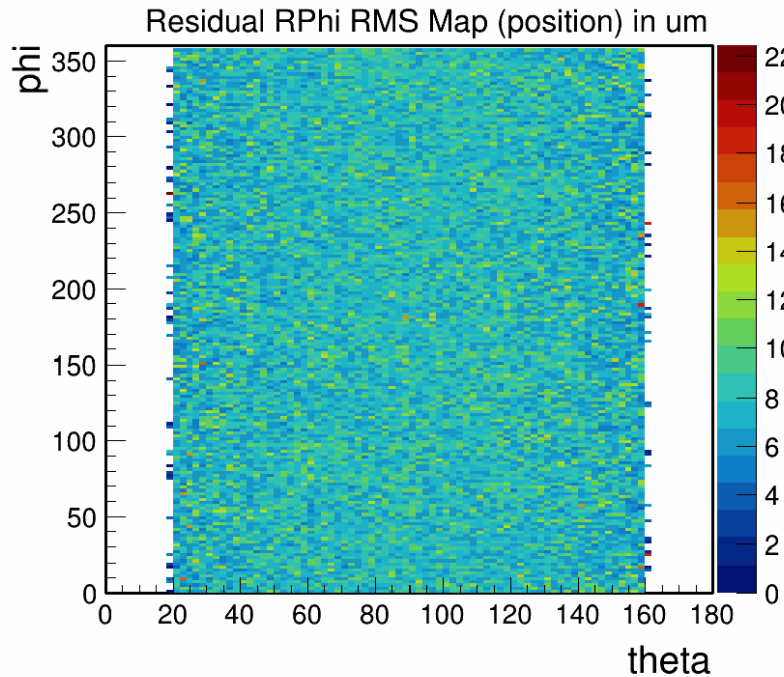
Clustering efficiency vs. polar angle

- Average detection efficiency 98.5%
- Average clustering efficiency >99.9%

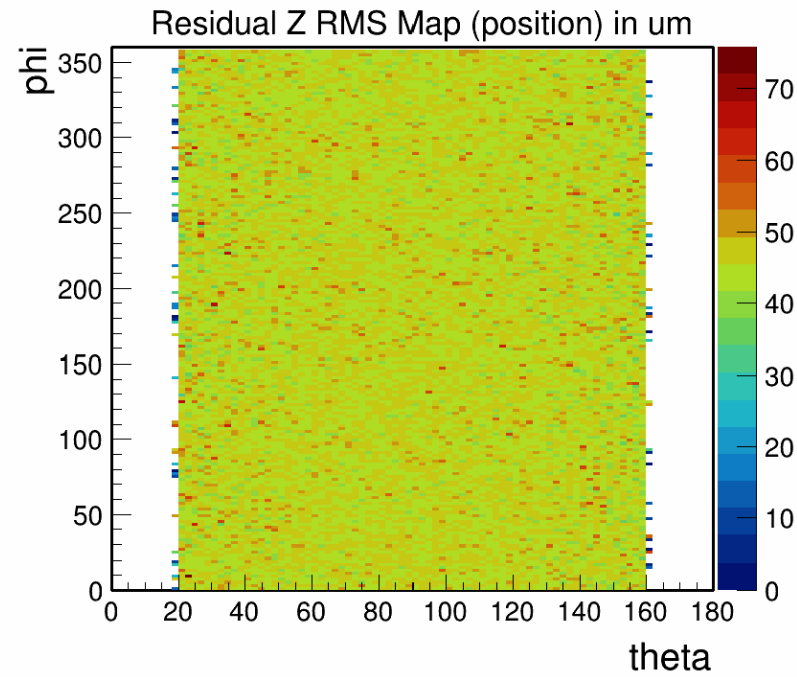
Position resolution



- Simulation settings:
 - 1GeV/c muon, θ range 20°-160°
 - Pixel threshold: 300e



Residual RMS (rphi)



Residual RMS (z)

- $\sigma_z = 37.4\mu m$
- $\sigma_{rphi} = 6.4\mu m$

- ✓ No correlation between pixel position and position resolution
- ✓ The resolution is better than $(\text{pixel pitch})/\sqrt{12}$ due to the charge information

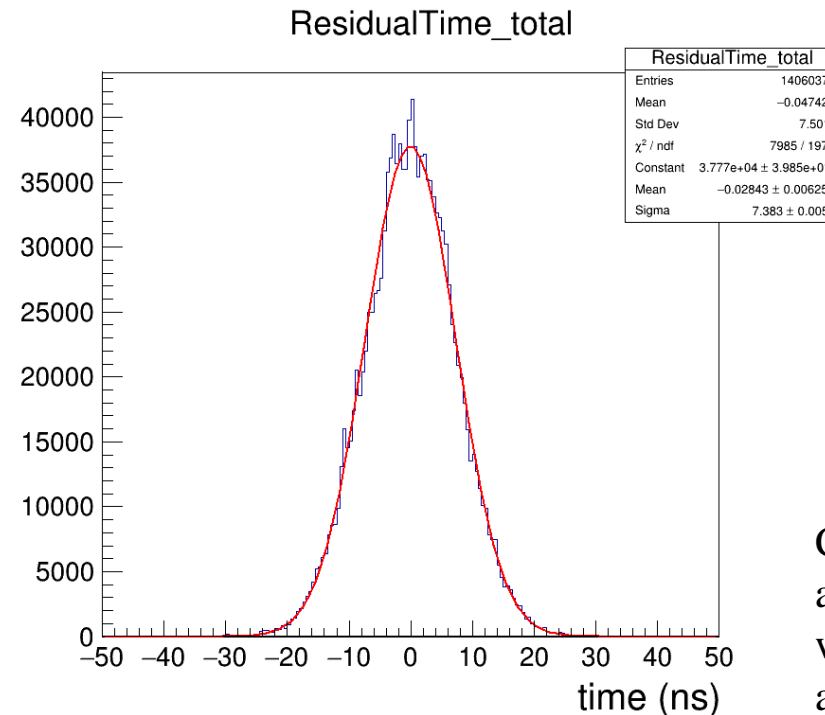
Timing performance



- Simulation settings:
 - 1GeV/c muon, θ range 20°-160°
 - Pixel threshold: 300e

Method

- Pixel with **largest** charge (TOT) is chosen as “seed”
- Seed pixel’s TOA **calibrated by TA-relationship** gives the time stamp of this cluster
- Compared with the MC hit time to get residual



Time resolution
~7.4ns

Contributions from noise and TDC not included, which are simulated to be about **30ns**

- MAPS-based inner tracker for STCF is under R&D in USTC, aiming at :
 - $\sigma_{r\phi} < 100\mu m$
 - material budget 0.3% X_0 per layer
- TCAD simulation conducted for 4 different technologies:
 - TJ180nm standard, BCIS90nm, GSMC130nm, TJ180nm modified
- ITKM full simulation chain is accomplished under OSCAR framework
 - Two different digitization methods implemented and their performance well studied
 - Cluster reconstruction of 1GeV/c muons shows good performance of ITKM:
 - ✓ Average detection efficiency 98.5%
 - ✓ Position resolution: $\sigma_z = 37.4\mu m$, $\sigma_{rphi} = 6.4\mu m$
 - ✓ Time resolution (sensor only) 7.4ns

In the future:

- Track reconstruction study
- MAPS sensor structure optimization
- ITKM geometry optimization

Thanks!

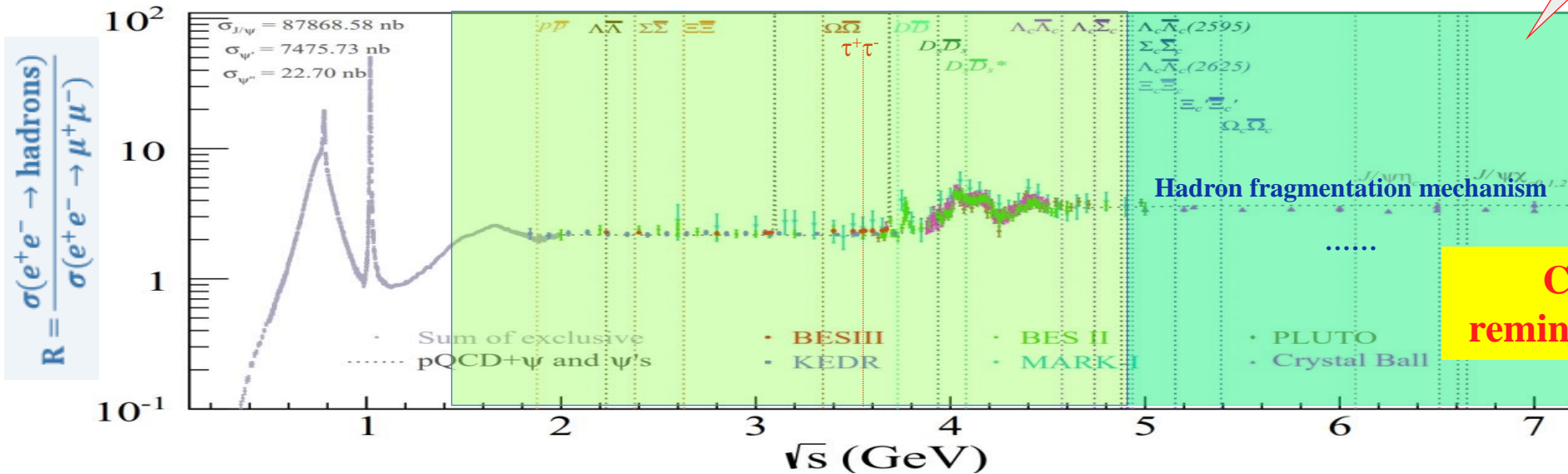
Backup

Features at Tau-Charm energy region



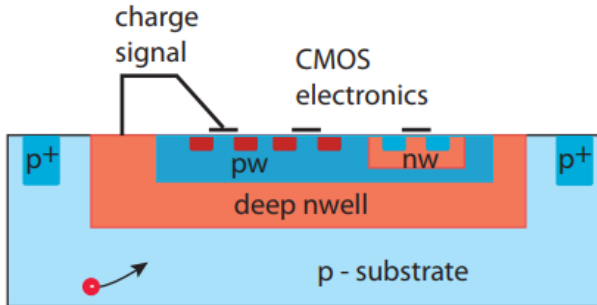
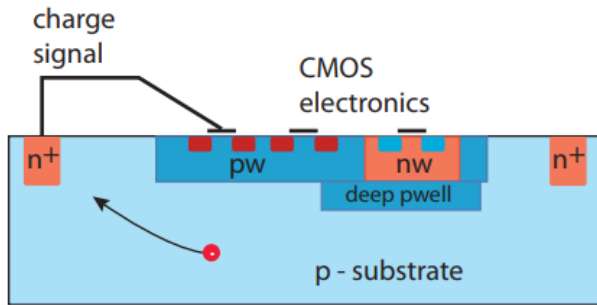
- Tau-Charm energy region (2-5GeV):
 - **Transition region** between perturbative and non-perturbative QCD
 - **Rich** of resonances structures
 - **Threshold** of pair production of hadrons and tau leptons
 - **Mass location** where exotic hadrons, gluonic matter and hybrid exist
- **Rich physics programs in the tau-charm region to be explored**

No e⁺e⁻ Collider
Opportunity
for future TCF



Crucial to meet the
reminding challenges of SM

HR-MAPS or HV-MAPS?



Low material budget

- Power consumption $< 100 \text{ mW/cm}^2$
- Thin silicon layer $\sim 50 \mu\text{m}$

High hit rate

- Fast readout

Moderate timing of $\sim 50\text{ns}$

- Fast charge collection
- Record TOA & TOT information

Moderate position resolution requirements

- Enlarge pixel size if necessary (especially in z direction)

Other considerations

- Technology availability
- Cost-effective

HR-MAPS with pixel size **$170\mu\text{m} \times 30\mu\text{m}$** chosen as the baseline design

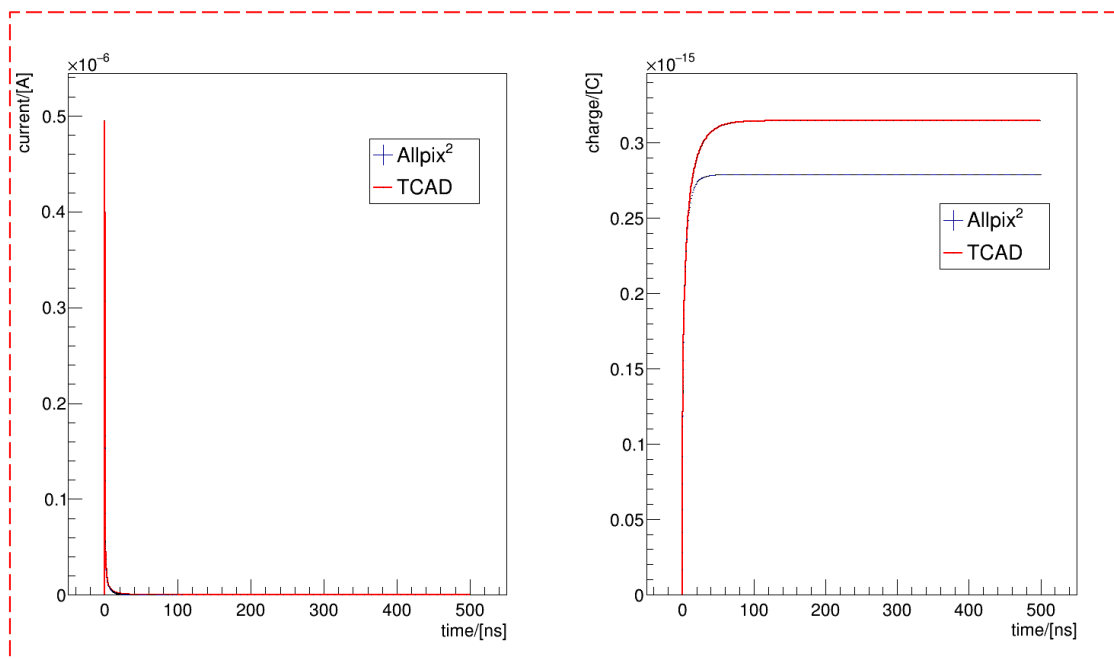
Comparison of TCAD and Allpix² signals



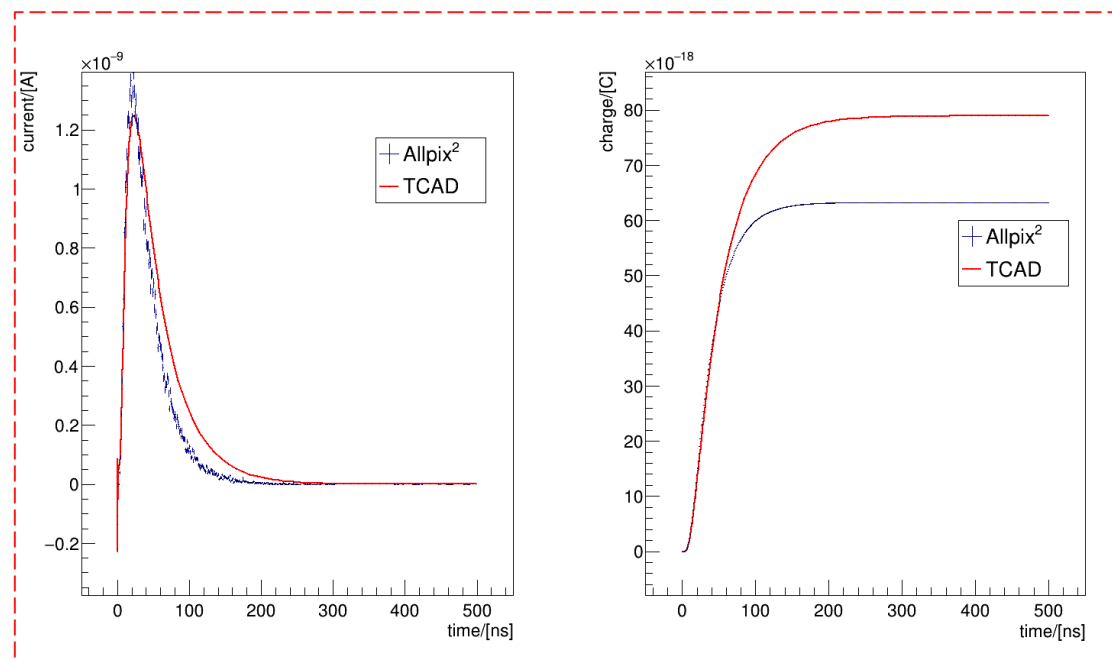
- TJ180nm techno, nwell size $2\mu m$, spacing $2\mu m$
- nwell 0.8V, substrate -6V
- Ionization density $80e^-/\mu m$

```
[DepositionPointCharge]
source_type = "mip"
model = "spot"
spot_size = 0.0354um
# position = 1596um 8441.75um
position = 1611.96um 8526.1675um
# position = 0 0
number_of_steps = 100
number_of_charges = 80/um
```

Settings in Allpix²



Injection from pixel center



Injection from pixel corner

Details of digitization



- Three digitization options available:
 - 0: sampling
 - 1: Full sim based on Allpix², only electron propagation considered (default for now)
 - 2: Full sim based on Allpix², both electron & hole propagation considered
- Optional physics models for different physics process



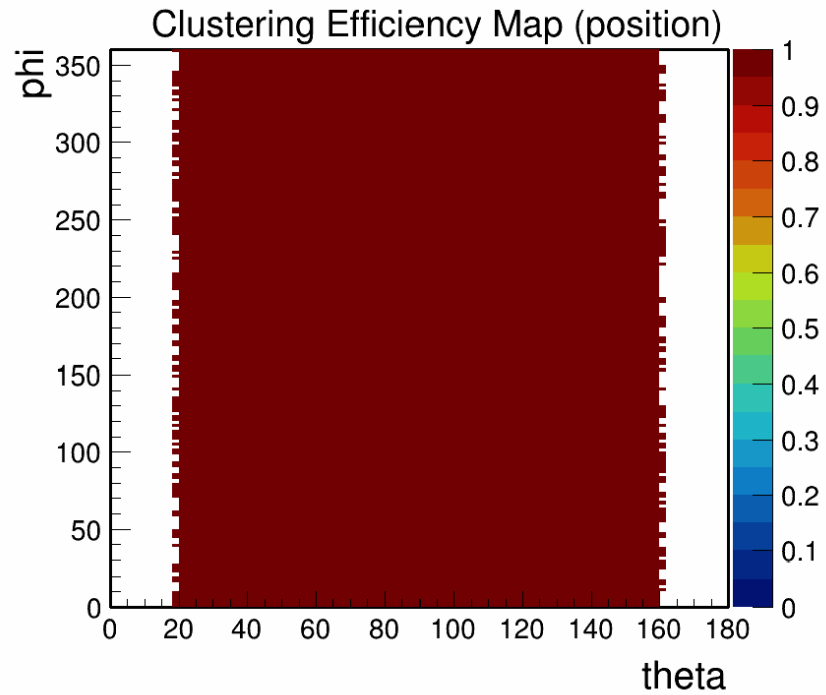
More accurate
but
Slower

```
# set physics models for full digitization
# modility model: jacoboni/canali/canali_fast/hamburg/hamburg_highfield/masetti/masetti_canali(default)/arora/ruch_kino/quay/levinshtein/constant
ITKMDigi.property("mobility_model").set("masetti_canali")
# recombination model: srh/auger/srh_auger(default)/constant/none
ITKMDigi.property("recombination_model").set("srh_auger")
# multiplication model: massey/massey_optimized/overstraeten/overstraeten_optimized/okuto/okuto_optimized/bologna/none(default)
ITKMDigi.property("multiplication_model").set("none")
# trapping model: ljubljana/kramberger/dortmund/krasel/cmstracker/mandic/constant/none(default)
ITKMDigi.property("trapping_model").set("none")
# detrapping model: constant/none(default)
ITKMDigi.property("detrapping_model").set("none")
```

Clustering efficiency



- Simulation settings:
 - 1GeV/c muon, θ range 20°-160°
 - Pixel threshold: 300e

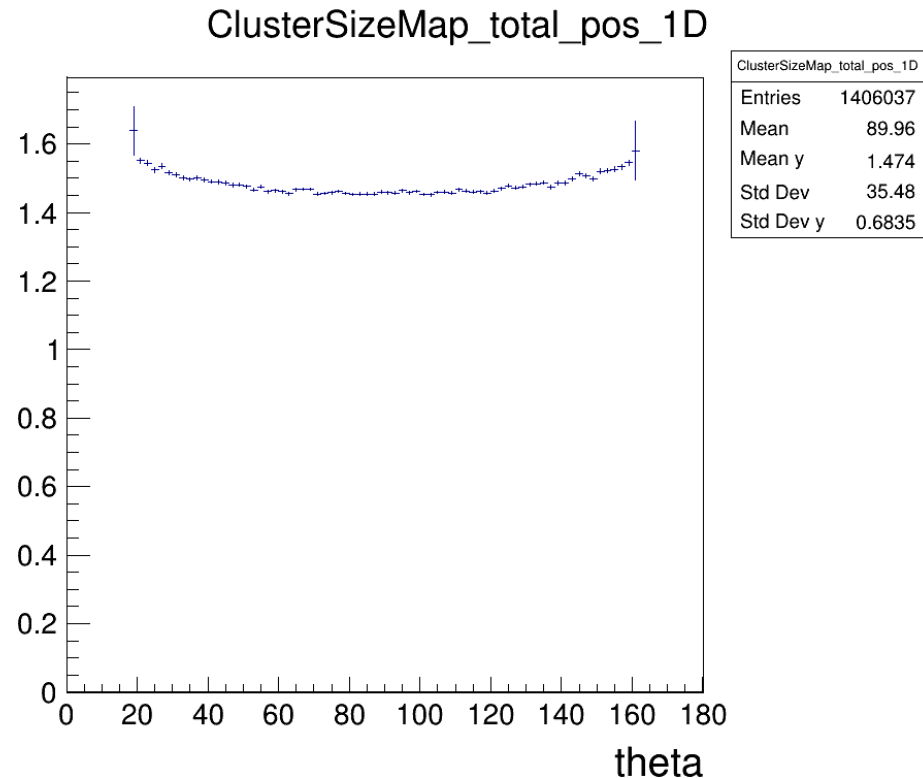


Average Efficiency vs.
polar & azimuthal angle

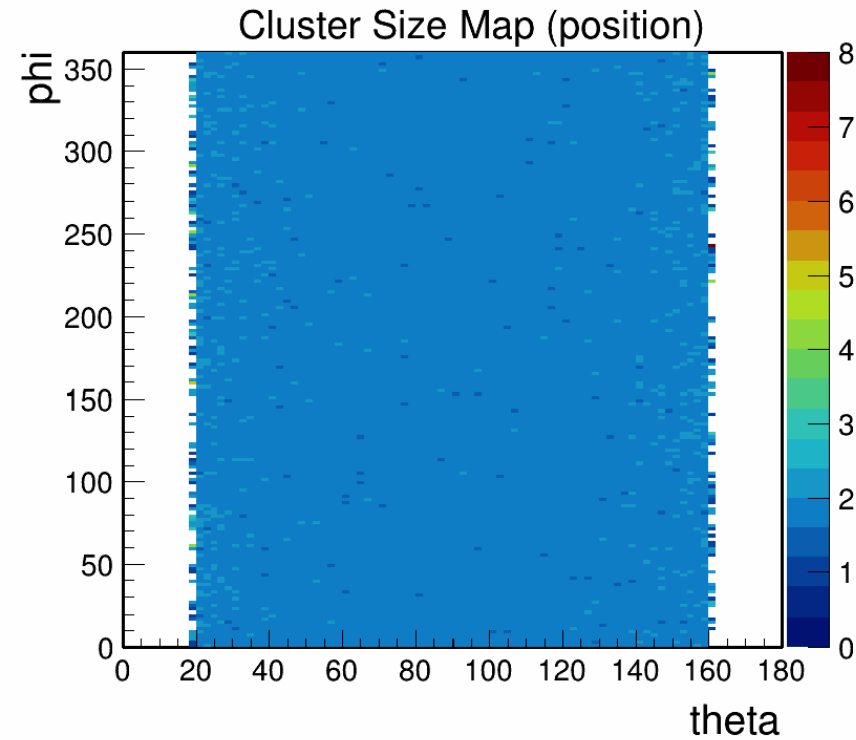
Cluster size



- Simulation settings:
 - 1GeV/c muon, θ range 20°-160°
 - Pixel threshold: 300e



Cluster size vs. polar angle



Cluster size vs. polar & azimuthal angle

Average cluster size 1.47

Clustering performance in local coordinate

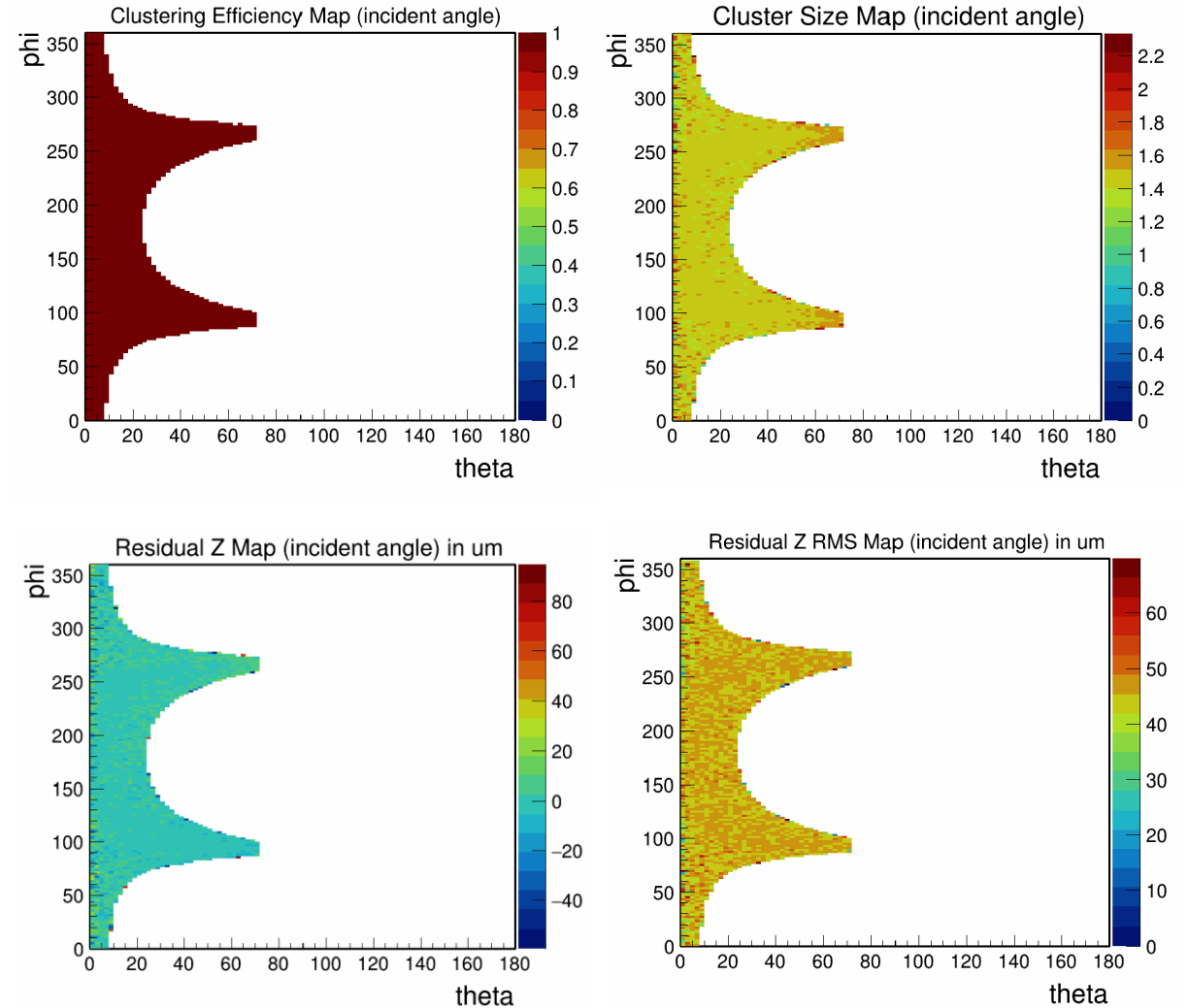
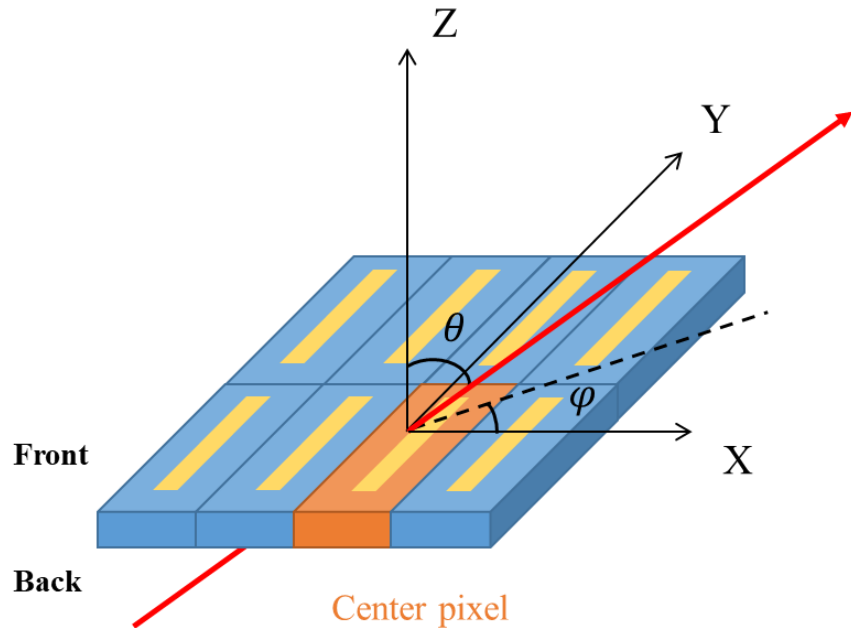


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- Simulation settings:

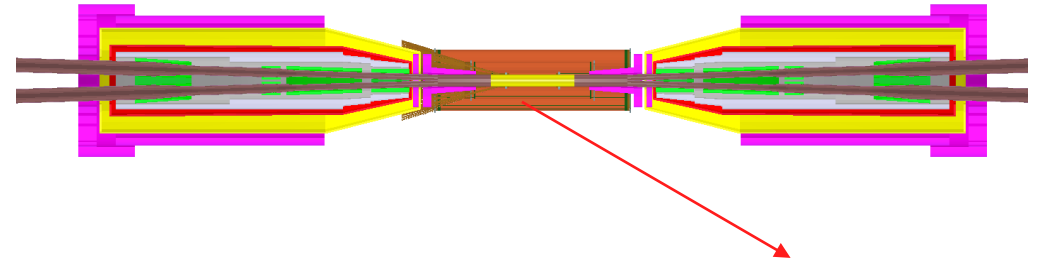
- 1GeV/c muon, θ range 20°-160°
- Pixel threshold: 300e



ITKM background estimation



- Background simulation carried out under OSCAR framework
- Three types backgrounds combined: **Touschek (main background), Luminosity, Beam-gas**
- Latest bkg generators and MDI design
- **Simulation + Digitization** to get the background hit rate **in terms of fired pixels**



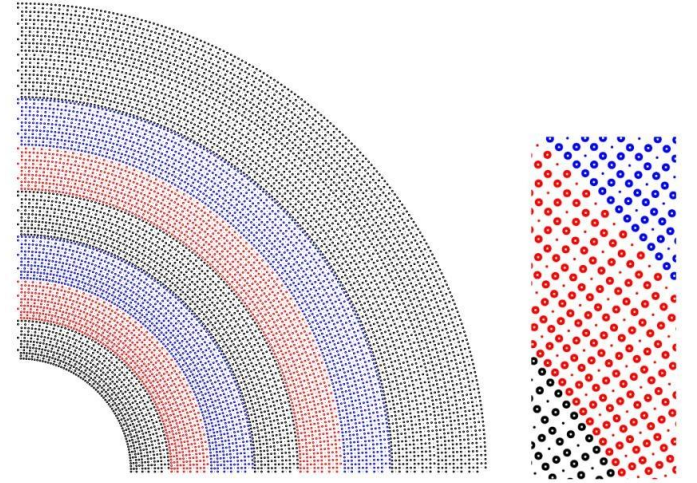
Three layers of ITKM

	Total hit rate / Hz	Average hit rate per unit area / (kHz/cm ²)	Maximum hit rate per unit area / (kHz/cm ²)
ITKM1	2.4E+08	411.7779	440.78
ITKM2	47691165	12.25144	14.66
ITKM3	47566214	4.699801	5.47

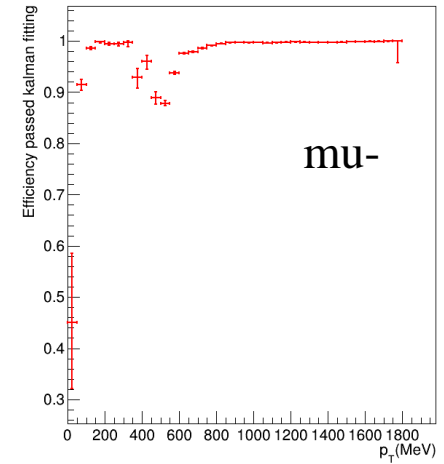
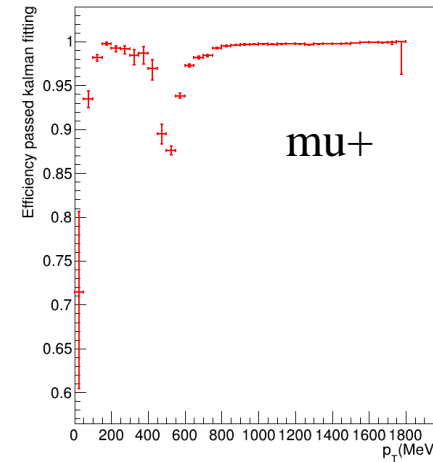
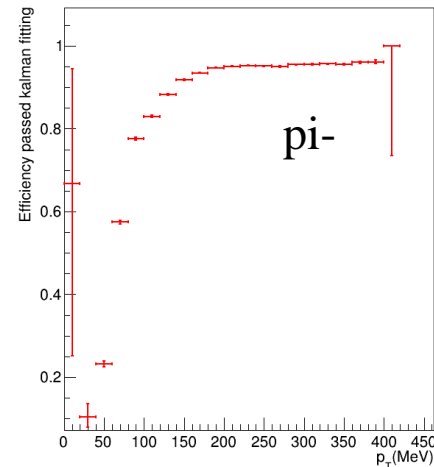
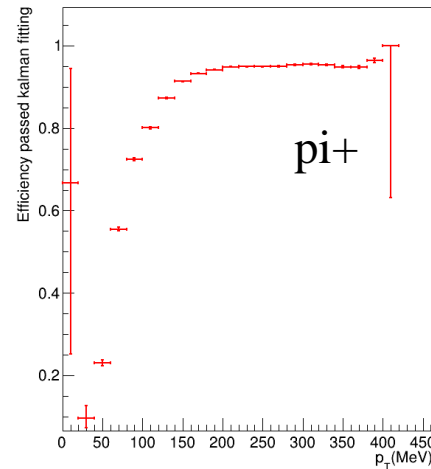
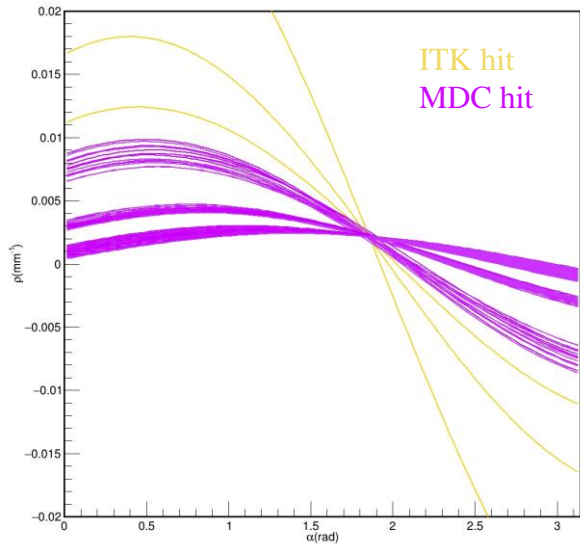
Preliminary results on track reconstruction



- ITKM and MDC(Drift Chamber) together form the tracking system of STCF
- Basic idea of track finding: conformal transform + Hough transform
- Track fitting uses generic track-fitting toolkit Genfit2



Hough space



Tracking efficiency for $\psi(3686) \rightarrow \pi^+ \pi^- J/\psi(\mu^+ \mu^-)$